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I HEREBY CERTIFY THAT THIS CORRESPONDENCE IS BEING DEPOSITED WITH THE UNITED STATES POSTAL SERVICE WITH SUFFICIENT POSTAGE AS FIRST CLASS MAIL IN AN ENVELOPE ADDRESSED TO THE COMMISSIONER FOR PATENTS, P.O. BOX 1450, ALEXANDRIA, VA 22313-1450 ON: May 10, 2005

Name of Person Making Deposit: ROBERT FABER

Signature: Robert Faber

Date of Signature: 5-10-05

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:
Victor Ku *et al.*

Examiner: Phuc T. Dang

Application No.: 10/707,759

Group Art Unit: 2818

Filed: January 9, 2004

For: METHOD OF FORMING FET
SILICIDE GATE STRUCTURES
INCORPORATING INNER
SPACERS

Date: May 9, 2005

AMENDMENT AFTER ALLOWANCE UNDER 37 C.F.R. § 1.312

Mail Stop Issue Fee
The Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Notice of Allowance dated April 29, 2005, please amend the above-identified application as follows: